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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/666,354	09/19/2003	Hui-Lin Chang	TS02-1079	. 8188
42717 7590 12/21/2006 HAYNES AND BOONE, LLP 901 MAIN STREET, SUITE 3100			EXAMINER	
			ANGADI, MAKI A	
DALLAS, TX 75202		N.	ART UNIT	PAPER NUMBER
			1765	
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SHORTENED STATUTO	RY PERIOD OF RESPONSE	MAIL DATE	DELIVERY MODE	
3 MC	ONTHS	12/21/2006	PAPER	

Please find below and/or attached an Office communication concerning this application or proceeding.

If NO period for reply is specified above, the maximum statutory period will apply and will expire 6 MONTHS from the mailing date of this communication.

Office Action Summary National Content		Application No.	Applicant(s)				
Maki A. Angadi		10/666,354	CHANG ET AL.				
Period for Reply A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE 3 MONTH(S) OR THIRTY (30) DAYS, WHICHEVER IS LONGER, FROM THE MAILING DATE OF THIS COMMUNICATION. Edutinated or time may be waited under the provides of 37 CFR 1.35(a). In a event, however, may a reply be timely filed after 50 kg by MONTHS from the mailing date of this communication of 37 CFR 1.35(a). In a event, however, may a reply be timely filed after 50 kg by MONTHS from the mailing date of this communication of the special part of the communication. Failure for prov. Which the set or estimate adjustment. See 37 CFR 1.704(b). Status 1 ∑ Responsive to communication(s) filed on 25 October 2006. 2a)∑ This action is FINAL. 2b)☐ This action is non-final. 3]☐ Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under Ex parte Quayle, 1935 C.D. 11, 453 O.G. 213. Disposition of Claims 4 ∑ Claim(s) 1-34 is/are pending in the application. 4a) Of the above claim(s) is/are withdrawn from consideration. 5 ∑ Claim(s) 2-34 is/are allowed. 6 ∑ Claim(s) 1-22 is/are rejected. 7 ☐ Claim(s) as subject to restriction and/or election requirement. Application Papers 9 ☐ The specification is objected to by the Examiner. 10 ☐ The drawing(s) filed on is/are: a)☐ accepted or b)☐ objected to by the Examiner. Application Papers 9 ☐ The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152. Priority under 35 U.S.C. § 119 12 ☐ Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f). 3 ☐ All b)☐ Some * c)☐ None of. 1.☐ Certified copies of the priority documents have been received in Application No 2.☐ Certified copies of the priority documents have been received in Application No 3.☐ Copies of the certified copies of the priority documents have been received.	Office Action Summary	Examiner	Art Unit				
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WHICHEVER IS LONGER, FROM THE MAILING DATE OF THIS COMMUNICATION. Extensions of time may be audiable under the provisions of 37 CFR 1.136). In or event, however, may a reply be alreafied above, the maximises of 37 CFR 1.136). In or event, however, may a reply be indeed above, the maximises of 37 CFR 1.136). In order, however, may a reply be indeed above, the maximises and will expire SIX (8) MONTHS from the mailing date of this communication. If NO period for reply a specified above, the maximise maturally prior of will apply and will expire SIX (8) MONTHS from the mailing date of this communication. Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any earned patient term adjustment. See 37 CFR 1.704(b). Status 1) Responsive to communication(s) filed on 25 October 2006. 2a) This action is FINAL. 2b) This action is non-final. 3) Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under Ex parte Quayle, 1935 C.D. 11, 453 O.G. 213. Disposition of Claims 4) Claim(s) 1-34 is/are pending in the application. 4a) Of the above claim(s) is/are withdrawn from consideration. 5) Claim(s) 24-34 is/are allowed. 6) Claim(s) 1-23 is/are rejected. 7) Claim(s) 24-34 is/are allowed. 8) Claim(s) 1-23 is/are rejected. 7) Claim(s) 24-35 is/are rejected to 8.20 claim(s) 1-23 is/are rejected to 9.20 claim(s) 1-23 is/are allowed. 8) Claim(s) 24-35 is/are allowed. 8) Claim(s) 1-28 is/are allowed. 8) Claim(s) 1-28 is/are allowed. 8) Claim(s) 24-36 is/are allowed. 10) The specification is objected to by the Examiner. Application Papers 9) The specification is objected to by the Examiner. Application Papers 9) The specification is objected to by the Examiner. Application Papers 10) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f). 11) Acknowledgment is made of a claim for foreign priority	·						
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12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f). a) All b) Some * c) None of: 1. Certified copies of the priority documents have been received. 2. Certified copies of the priority documents have been received in Application No 3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)). * See the attached detailed Office action for a list of the certified copies not received. Attachment(s) 1) Notice of References Cited (PTO-892)	11) The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152.						
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DETAILED ACTION

Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

This application currently names joint inventors. In considering patentability of the claims under 35 U.S.C. 103(a), the examiner presumes that the subject matter of the various claims was commonly owned at the time any inventions covered therein were made absent any evidence to the contrary. Applicant is advised of the obligation under 37 CFR 1.56 to point out the inventor and invention dates of each claim that was not commonly owned at the time a later invention was made in order for the examiner to consider the applicability of 35 U.S.C. 103(c) and potential 35 U.S.C. 102(e), (f) or (g) prior art under 35 U.S.C. 103(a).

 Claims 1,3, 5, 7-10, 12,13,15, 18-21, 23 are rejected under 35 U.S.C. 103(a) as being unpatentable over Kim (US Pub No. 2002/0106891).

As to claim 1, Kim discloses a method of fabricating a semiconductor device having a low dielectric layer (paragraph 0002) consisting of

(a) substrate (100) (Fig.2) (paragraph 0035);

- (b) Forming a low k dielectric layer consisting of an silicon oxycarbide layer (110) (organo-silicon material) on said substrate (paragraph 0035);
- (c) Performing a treatment of He plasma on said low k dielectric layer in a process chamber to form a transformed low k dielectric layer (paragraph 0036); and
- (d) Performing treatment with H₂ plasma on the transformed low k dielectric layer in a process chamber (paragraph 0048)(Table 1).

Although the reference of Kim discloses that hydrogen and helium are suitable plasmas for forming a layer of an organic polymer group over the regenerated surface of silicon oxycarbide, the reference fails to disclose a specific example wherein a first plasma treatment is conducted using helium plasma gas followed by a second treatment using hydrogen gas.

Kim suggests the use of He, O₂ and H₂ plasma treatment to modify the physical properties of layers (paragraph 0058). Kim, is however silent about the order of the plasma treatment. It is noted that Kim fails to disclose applicant's specific sequence of (a) a first treatment of He plasma and (b) second treatment of H₂ plasma. However, it would have been obvious to one of ordinary skill in the art at the time the invention was made to modify the sequence of steps in Kim to include any order of step (a) and (b) because the final product of Kim appears to be similar to the product produced by applicant's claimed sequence of processing steps. Since each step imparts separate and distinct properties to the

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dielectric material, it appears that a similar product would be produced regardless of the sequence of steps. Ex parte Rubin, 128 USPQ 440 (Bd. App. 1959).

As to claim 3, Kim discloses low k dielectric layer consisting of doped silicon oxide (paragraph 0058), hydrogen silsequioxane (HSQ), or methysilsequioxane (MSQ) (paragraph 0005).

As to claim 5, Kim discloses the use of plasma enhanced CVD (PECVD) for plasma treatment (paragraph 0062).

As to claim 7, Kim discloses the plasma treatment during a period of about 10-200 seconds (paragraph 0048) that overlap the values disclosed by the applicant.

As to claim 8, 18 and 30 Kim discloses the process chamber pressure in the range of about 1 to 10 Torr (paragraph 0048) that overlap the range disclosed by the applicant.

As to claim 9 and 19, Kim discloses the plasma treatment with RF power of about 200 Watts that is close to the value disclosed by the applicant. Therefore, it would be obvious to one of ordinary skill in the art at the time of invention to select the RF power suggested by the applicant because Kim

suggest that the process parameters can be changed according to the treatment conditions of subsequent process of a semiconductor device (paragraph 0048).

As to claim 10 and 20, Kim discloses that the substrate is heated between 250 to 400°C that overlaps the range suggested by the applicant.

As to claim 12, Kim discloses wherein the transformed low k dielectric layer (silicon oxycarbide layer) is enriched with Si-H bonds during the H_2 treatment (paragraph 0048).

As to claim 13, Kim discloses a method of lowering the dielectric constant and increasing the thermal and mechanical stability of a low k dielectric layer in a damascene process (paragraph 0051), consisting of:

- (a) Providing a substrate having an etch stop layer (131)(Fig.7 and 8) (paragraph 0052);
- (b) Depositing a low dielectric layer consisting of an organosilicon compound (111)(Fig. 7 and 8) (paragraph 0051)
- (c) Performing a first treatment consisting of He plasma on said low k dielectric layer in a process chamber to form a transformed low dielectric layer (paragraph 0062).
- (d) Performing a plasma treatment with H2 plasma on transformed low k dielectric layer for form a composite low k dielectric layer consisting of a

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transformed low k dielectric layer that is enriched in Si-H bonds (paragraph 0048) on a transformed low k dielectric layer that has a mechanically stabilized network of Si-O bonds (paragraph 0049).

- (e) Forming an opening/hole in the composite low dielectric layer that extends through said etch stop layer (paragraph 0051); and
- (f) Depositing a diffusion barrier layer on the sidewalls of said opening/hole, depositing a metal layer on said barrier that fills said opening/hole, and planarizing said metal layer and said diffusion barrier layer to a level that is coplanar with the composite low k dielectric layer (paragraph 0052).

Although Kim suggest the use of He plasma treatment in the formation of low k dielectric material, does not expressly disclose its use in the damascene process as claimed by the applicant.

Kim suggests the use of He, O₂ and H₂ plasma treatment to modify the physical properties of layers (paragraph 0058). Kim, is however silent about the order of the plasma treatment. It is noted that Kim fails to disclose applicant's specific sequence of (a) a first treatment of He plasma and (b) second treatment of H₂ plasma. However, it would have been obvious to one of ordinary skill in the art at the time the invention was made to modify the sequence of steps in Kim to include any order of step (a) and (b) because the final product of Kim appears to be similar to the product produced by applicant's claimed sequence of processing steps. Since each step imparts separate and distinct properties to the

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dielectric material, it appears that a similar product would be produced regardless of the sequence of steps. Ex parte Rubin, 128 USPQ 440 (Bd. App. 1959).

As to claim 15, Kim discloses that the thickness of low k dielectric layer is consisting of carbon doped silicon oxide layer is about 5000 Å (paragraph 0059).

As to claim 21, Kim discloses that low k dielectric layer enriched in Si-H bond has a thickness from about 5000 Å (0059).

As to claim 23, Kim discloses the use of Ti/TiN as the barrier metal layer and copper metal layer (paragraph 0057).

Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

- (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 2. Claims 2, 4, 6 11, 14, 16, 17, 22, 28 and 29 are rejected under 35 U.S.C. 103(a) as being unpatentable over Kim (US Pub No. 2002/0106891)(see teachings of Kim above) in view of Grill (US Patent No. 6,147,009).

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As to claim 2 and 14, Kim does not specifically disclose the process of curing the low k dielectric layer before performing the He plasma treatment. However, Grill discloses the heat treatment (curing) of film at a temperature not less than 300°C (col. 3, lines 1-2). Therefore, it would be obvious to one of ordinary skill in the art at the time of invention to select curing of dielectric layer because Grill reveals that curing process improves the stabilization of low-k film (col.7, lines 9-13). The selection of any order of curing is prima facie obvious. Ex parte Rubin, 128 USPQ 440 (Bd. App. 1959).

As to claim 4 and 16, Kim is silent about the atomic percentage ratios in the composition of SiCOH. However, Grill discloses the composition of SiCOH: about 5-40 atomic % of Si; about 5-45 atomic percent of C; about 0-50 atomic percent of O; about 10-55 atomic percent of H that overlap the atomic percent of compositions selected by the applicant (col.6, lines 25-33). Therefore, it would be obvious to one of ordinary skill in the art at the time of invention to modify the atomic percent of components because Grill illustrates that the atomic percent of compositions would determine thermal stability of low dielectric constant materials suitable for integration in a BEOL wiring structure (col.5, lines 12-17).

As to claim 6 and 17, Kim does not expressly disclose the gas flow rate. However, Grill discloses the precursor flow rate at between 5-200 sccm (col.3, lines 35-36). According to Grill, the films can be prepared by choosing a suitable

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precursor and a specific combination of processing parameters such as flow rate, pressure in reactor and substrate temperature (col.5, lines 38-42) that can be optimized to obtain low-k films. See MPEP § 2144.05 II. It would have been obvious to one of ordinary skill in the art to select any flow rate in the process of Kim, including applicant's flow rate in calim 6, because reference of Grill illustrates that flow rate is a parameter which can be optimized to obtain a low k film.

As to claim 11, Kim discloses the one or more gases selected from the group of He, H₂, O₂ and Ar in a substrate-loaded processing chamber (paragraph 0022). Kim does not expressly disclose whether the plasma treatment of different gases is done without breaking chamber vacuum. Grill discloses the use of insitu process for annealing and depositing of low k dielectric material to enhance the thermal stability of films (col.7, lines 1-13). Therefore, it would be obvious to one of ordinary skill in the art at the time of invention to perform first and second treatment in the same chamber without breaking chamber vacuum in the process of Kim because Grill suggests that in-situ process can enhance thermal stability of the low k dielectric films (col.7, lines 15-18).

As to claim 17, Kim discloses the duration of plasma treatment from about 30-50 second (paragraph 0048) that overlap the range cited by the applicant.

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As to claim 22, Kim does no expressly reveal the plasma treatment of first and second type in the same process chamber. Grill discloses the use of in-situ process for annealing and depositing of low k dielectric material to enhance the thermal stability of films (col.7, lines 1-13). Therefore, it would be obvious to one of ordinary skill in the art at the time of invention to perform first and second treatment in the same chamber because Kim suggests that in-situ process can

Response to Arguments

enhance thermal stability of the low k dielectric films (col.7, lines 15-18).

3. Applicant's arguments filed on 10/25/2006 have been fully considered but they are not persuasive.

With reference to claims 1 and 13, Kim discloses the plasma treatment by H₂ plasma and He plasma treatments (see Table I on page 3). Kim discloses the relative dielectric constant resulting from performing the plasma treatment of several types under the same conditions with the preferred embodiment after forming the silicon oxycarbide layer. Kim concludes that the plasma treatment does not have significant influence on the relative dielectric constant of the silicon oxycarbide layer (paragraph 0044).

However, in embodiment 2, Kim has demonstrated that when the H_2 -plasma is applied to silicon oxycarbide layer, the mechanical strength of the silicon carbide layer and the adhesive force with other layers are increased (paragraph 0049). In embodiment 3, Kim has demonstrated that using H_2 plasma

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treatment one can reduce the increase in the dielectric constant of silicon oxycarbide layer and mechanical damage (paragraph 0055). Kim further discloses the process of decreasing the parasitic capacitance by 15-30% in comparison with the conventional silicon oxycarbide that is not treated with H₂ plasma (paragraph 0059). Although there is no significant difference in terms of the dielectric constant of the silicon oxycarbide layer with H₂ or He plasma treatment, Kim demonstrates difference in other properties such as mechanical strength and parasitic capacitance of SiOC layer. As a result, any combination of plasma treatments with the disclosed known plasma would produce results that give rise to different physical properties of SiOC layer depending on the process parameters. Since both hydrogen and helium are suitable, a process involving both plasmas would not distinguish a process using single plasma.

Allowable Subject Matter

Claims 24-34 are allowable.

4. The following is a statement of reasons for the indication of allowable subject matter: The closest prior art of Kim (US Pub.No. 2002/0106891) does not teach or suggest applicants' step of "providing a substrate with a metal layer comprised of metal lines having a top surface and sidewalls formed thereon and an anti-reflective coating (ARC) formed on the top surface of said metal lines" as defined in claim 24.

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Conclusion

THIS ACTION IS MADE FINAL. Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the mailing date of this final action.

The prior art made of record and not relied upon is considered pertinent to applicant's disclosure. Chen (US Patent No. 5,858,869) discloses a method for fabricating inter-metal dielectric insulation using anisotropic plasma oxides and low dielectric constant polymers.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Maki A. Angadi whose telephone number is 571-272-8213. The examiner can normally be reached on 8 AM to 4.30 PM.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Nadine G. Norton can be reached on 571-272-1465. The fax phone number for the organization where this application or proceeding is

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assigned is 571-273-8300. Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Dr. Maki Angadi Examiner Art Unit 1765

> SHAMIM AHMED PRIMARY EXAMINER